

Research

SHORT COMMUNICATION

Solar Cell Efficiency Tables (Version 32)

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Consolidated tables showing an extensive listing of the highest independently confirmed efficiencies for solar cells and modules are presented. Guidelines for inclusion of results into these tables are outlined and new entries since January 2008 are reviewed. Copyright © 2008 John Wiley & Sons, Ltd.

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INTRODUCTION

Since January, 1993, 'Progress in Photovoltaics' has published six monthly listings of the highest confirmed efficiencies for a range of photovoltaic cell and module technologies.^{1–3} By providing guidelines for the inclusion of results into these tables, this not only provides an authoritative summary of the current state of the art but also encourages researchers to seek independent confirmation of results and to report results on a standardised basis. In the present paper, new results since January 2008 are briefly reviewed.

The most important criterion for inclusion of results into the tables is that they must have been measured by a recognised test centre listed in an earlier issue.² A distinction is made between three different eligible areas: total area; aperture area and designated illumination area.¹ 'Active area' efficiencies are not included. There are also certain minimum values of the area sought for the different device types (above 0.05 cm² for a concentrator cell, 1 cm² for a 1-sun cell, and 800 cm² for a module).¹

Results are reported for cells and modules made from different semiconductors and for sub-categories within each semiconductor grouping (e.g. crystalline, polycrystalline and thin film).

NEW RESULTS

Highest confirmed cell and module results are reported in Tables I, II and IV. Any changes in the tables from those previously published³ are set in bold type. In most cases, a literature reference is provided that describes either the result reported or a similar result. Table I summarises the best measurements for cells and submodules, Table II shows the best results for modules and Table IV shows the best results for concentrator cells and concentrator modules. Table III contains what might be described as 'notable exceptions'. While not conforming to the requirements to be recognised as a class record, the cells and modules in this table have notable characteristics that will be of interest to sections of the photovoltaic community with entries based on their significance and timeliness.

To ensure discrimination, Table III is limited to nominally 10 entries with the present authors having voted for their preferences for inclusion. Readers who

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Table I. Confirmed terrestrial cell and submodule efficiencies measured under the global AM1.5 spectrum (1000 W/m²) at 25°C

Classification*	Effic. [†] (%)	Area [‡] (cm ²)	V _{oc} (V)	J _{sc} (mA/cm ²)	FF [§] (%)	Test centre (and date)	Description
Silicon							
Si (crystalline)	24.7 ± 0.5	4.00 (da)	0.706	42.2	82.8	Sandia (3/99)	UNSW PERL ¹⁰
Si (multicrystalline [¶])	20.3 ± 0.5	1.002 (ap)	0.664	37.7	80.9	NREL (5/04)	FhG-ISE ¹¹
Si (thin-film transfer)	16.6 ± 0.4	4.017 (ap)	0.645	32.8	78.2	FhG-ISE (7/01)	U. Stuttgart (45 μm thick) ¹²
Si (thin-film submodule)	10.4 ± 0.3	94.0 (ap)	0.492 [¶]	29.5 [¶]	72.1	FhG-ISE (8/07)	CSG Solar (1–2 μm on glass; 20 cells) ¹³
III–V cells							
GaAs (crystalline)	25.9 ± 0.8	0.998 (ap)	1.038	29.4	84.7	FhG-ISE (12/07)	Radboud U. Nijmegen⁵
GaAs (thin film)	24.5 ± 0.5	1.002 (t)	1.029	28.8	82.5	FhG-ISE (5/05)	Radboud U. Nijmegen ⁵
GaAs (multicrystalline)	18.2 ± 0.5	4.011 (t)	0.994	23.0	79.7	NREL (11/95)	RTI, Ge substrate ¹⁴
InP (crystalline)	21.9 ± 0.7	4.02 (t)	0.878	29.3	85.4	NREL (4/90)	Spire, epitaxial ¹⁵
Thin-film chalcogenide							
CIGS (cell)	19.2 ± 0.6[#]	0.994(ap)	0.716	33.3	80.3	NREL (1/08)	NREL, CIGS on glass⁶
CIGS (submodule)	16.6 ± 0.4	16.0 (ap)	0.661 [¶]	33.4 [¶]	75.1	FhG-ISE (3/00)	U. Uppsala, four serial cells ¹⁶
CdTe (cell)	16.5 ± 0.5 [#]	1.032 (ap)	0.845	25.9	75.5	NREL (9/01)	NREL, mesa on glass ¹⁷
Amorphous/nanocrystalline Si							
Si (amorphous) ^{**}	9.5 ± 0.3	1.070 (ap)	0.859	17.5	63.0	NREL (4/03)	U. Neuchatel ¹⁸
Si (nanocrystalline)	10.1 ± 0.2	1.199 (ap)	0.539	24.4	76.6	JQA (12/97)	Kaneka (2 μm on glass) ¹⁹
Photochemical							
Dye sensitised ^{††}	10.4 ± 0.3	1.004(ap)	0.729	21.8	65.2	AIST (8/05)	Sharp ²⁰
Dye sensitised (submodule)^{††}	8.2 ± 0.3	25.45 (ap)	0.703[¶]	19.0[¶]	61.2	AIST (12/07)	Sharp, nine serial cells⁷
Dye sensitised (submodule)^{††}	8.2 ± 0.3	18.50 (ap)	0.659[¶]	19.8[¶]	62.9	AIST (6/08)	Sony, eight serial cells⁸
Organic							
Organic polymer ^{††}	5.15 ± 0.3	1.021(ap)	0.876	9.40	62.5	NREL(12/06)	Konarka ²¹
Organic (submodule)^{††}	1.1 ± 0.3	232.8 (ap)	29.3	0.072	51.2	NREL (3/08)	Plextronics (P3HT/PCBM)⁹
Multijunction devices							
GaInP/GaAs/Ge	32.0 ± 1.5	3.989(t)	2.622	14.37	85.0	NREL (1/03)	Spectrolab (monolithic)
GaInP/GaAs	30.3	4.0 (t)	2.488	14.22	85.6	JQA (4/96)	Japan Energy (monolithic) ²²
GaAs/CIS (thin film)	25.8 ± 1.3	4.00 (t)	—	—	—	NREL (11/89)	Kopin/Boeing (4-terminal) ²³
a-Si/μc-Si (thin submodule) ^{‡‡}	11.7 ± 0.4	14.23(ap)	5.462	2.99	71.3	AIST (9/04)	Kaneka (thin film) ²⁴

*CIGS, CuInGaSe₂; a-Si, amorphous silicon/hydrogen alloy.

[†]Effic., efficiency.

[‡](ap), aperture area; (t), total area; (da), designated illumination area.

[§]FF, fill factor.

^{||}FhG-ISE, Fraunhofer Institut für Solare Energiesysteme; JQA, Japan Quality Assurance; AIST, Japanese National Institute of Advanced Industrial Science and Technology.

[¶]Reported on a 'per cell' basis.

[#]Not measured at an external laboratory.

^{**}Stabilised by 800 h, 1 sun AM1.5 illumination at a cell temperature of 50°C.

^{††}Stability not investigated.

^{‡‡}Stabilised by 174 h, 1 sun illumination after 20 h, 5 sun illumination at a sample temperature of 50°C.

have suggestions of results for inclusion into this table are welcome to contact any of the authors with full details. Suggestions conforming to the guidelines will be included on the voting list for a future issue. (A smaller number of 'notable exceptions' for concentrator cells and modules additionally is included in Table IV, as are results under a relatively new low aerosol optical depth direct-beam spectrum⁴).

Six new results are reported in the present versions of the tables, only slightly down from the record number of eight in the previous version.³

The first new result appears in Table I. An efficiency of 25.9% was measured at the Fraunhofer Institute for Solar Energy Systems (FhG-ISE) for a 1 cm² GaAs cell fabricated by Radboud University Nijmegen of the Netherlands. This result displaced one of the oldest

Table II. Confirmed terrestrial module efficiencies measured under the global AM1.5 spectrum (1000 W/m²) at a cell temperature of 25°C

Classification*	Effic. [†] (%)	Area [‡] (cm ²)	V _{oc} (V)	I _{sc} (A)	FF [§] (%)	Test centre (and date)	Description
Si (crystalline)	22.7 ± 0.6	778 (da)	5.60	3.93	80.3	Sandia (9/96)	UNSW/Gochermann ²⁵
Si (large crystalline)	20.1 ± 0.6	16 300 (ap)	66.1	6.30	78.7	Sandia (8/07)	SunPower ²⁶
Si (multicrystalline)	15.3 ± 0.4	1017 (ap)	14.6	1.36	78.6	Sandia (10/94)	Sandia/HEM ²⁷
Si (thin-film polycrystalline)	8.2 ± 0.2	661 (ap)	25.0	0.318	68.0	Sandia (7/02)	Pacific Solar (1–2 μm on glass) ²⁸
CIGSS	13.4 ± 0.7	3459 (ap)	31.2	2.16	68.9	NREL (8/02)	Showa Shell (Cd free) ²⁹
CdTe	10.7 ± 0.5	4874 (ap)	26.21	3.205	62.3	NREL (4/00)	BP Solarex ³⁰
a-Si/a-SiGe/a-SiGe (tandem) [¶]	10.4 ± 0.5	905 (ap)	4.353	3.285	66.0	NREL (10/98)	USSC (a-Si/a-Si/a-Si:Ge) ³¹

*CIGSS, CuInGaS₂; a-Si, amorphous silicon/hydrogen alloy; a-SiGe, amorphous silicon/germanium/hydrogen alloy.

[†]Effic., efficiency.

[‡](ap), aperture area; (da), designated illumination area.

[§]FF, fill factor.

^{||}Not measured at an external laboratory.

[¶]Light soaked at NREL for 1000 h at 50°C, nominally 1 sun illumination.

results in the previous editions of these tables, a 25.1% efficient cell made by the Kopin Corporation in 1990. Radboud University also have previously fabricated the best thin-film GaAs cell listed in Table I.⁵ A paper on this work is in preparation.

The second new result also appears in Table I where efficiency improvement to 19.2% is reported for a 1 cm² thin-film polycrystalline CIGS (copper indium gallium diselenide) cell fabricated and measured by the National Renewable Energy Laboratory (NREL)⁶ improving on the Laboratory's earlier 18.8% result.

The third new result again appears in Table I where 8.2% efficiency is reported for a 25 cm² dye sensitised cell submodule fabricated by Sharp⁷ and measured by the Japanese National Institute of Advanced Industrial Science and Technology (AIST). This improves the company's previous benchmark of 7.9% efficiency for such a submodule.

The fourth new result is also reported for the same category in Table I where an 8.2% efficiency is also reported for a similarly sized dye sensitised cell submodule (18.5 cm²) fabricated by Sony⁸ and measured by AIST.

Table III. 'Notable exceptions': 'top 10' confirmed cell and module results, not class records (global AM1.5 spectrum, 1000 W/m², 25°C)

Classification*	Effic. [†] (%)	Area [‡] (cm ²)	V _{oc} (V)	J _{sc} (mA/cm ²)	FF (%)	Test centre (and date)	Description
Cells (silicon)							
Si (MCZ crystalline)	24.5 ± 0.5	4.0 (da)	0.704	41.6	83.5	Sandia (7/99)	UNSW PERL, SEH MCZ substrate ³²
Si (moderate area)	23.7 ± 0.5	22.1 (da)	0.704	41.5	81.0	Sandia (8/96)	UNSW PERL, FZ substrate ²⁵
Si (large FZ crystalline)	21.8 ± 0.7	147.4 (t)	0.677	40.0	80.6	FhG-ISE (3/06)	SunPower FZ substrate ³³
Si (large CZ crystalline)	22.3 ± 0.6	100.5 (t)	0.725	39.1	79.1	AIST (7/07)	Sanyo HIT, n-type CZ substrate ³⁴
Si (large multicrystalline)	18.1 ± 0.5	137.7 (t)	0.636	36.9	77.0	FhG-ISE (8/05)	U. Konstanz, laser grooved ³⁵
Cells (other)							
GaInP/GaInAs/GaInAs (tandem)	33.8 ± 1.5	0.25 (ap)	2.960	13.1	86.8	NREL (1/07)	NREL, monolithic ³⁶
CIGS (thin film)	19.9 ± 0.6	0.419 (ap)	0.692	35.5	81.0	NREL (10/07)	NREL, CIGS on glass ³⁷
a-Si/a-Si/a-SiGe (tandem)	12.1 ± 0.7	0.27 (da)	2.297	7.56	69.7	NREL (10/96)	USSC stabilised (monolithic) ³⁸
Photoelectrochemical [§]	11.1 ± 0.3	0.219 (ap)	0.736	20.9	72.2	AIST (3/06)	Sharp, dye sensitised ³⁹
Organic	5.4 ± 0.3 [§]	0.096 (ap)	0.856	9.70	65.3	NREL (7/07)	Plextronics ⁹

*CIGS, CuInGaSe₂.

[†]Effic., efficiency.

[‡](ap), aperture area; (t), total area; (da), designated illumination area.

[§]Stability not investigated.

^{||}Not measured at an external laboratory.

Table IV. Terrestrial concentrator cell and module efficiencies measured under the direct-beam AM1.5 spectrum at a cell temperature of 25°C

Classification	Effic.* (%)	Area [†] (cm ²)	Intensity [‡] (suns)	Test centre (and date)	Description
Single Cells					
GaAs	27.8 ± 1.0	0.203 (da)	216	Sandia [§] (8/88)	Varian, Entech cover ⁴⁰
Si	27.3 ± 1.0	1.00 (da)	93	FhG-ISE (9/07)	Amonix back-contact ⁴¹
CIGS (thin film)	21.5 ± 1.5	0.102 (da)	14	NREL (2/01)	NREL
Multijunction cells					
GaInP/GaAs/Ge (2-terminal)	34.7 ± 1.7	0.267(da)	333	NREL (9/03)	Spectrolab, monolithic
Submodules					
GaInP/GaAs/Ge	27.0 ± 1.5	34 (ap)	10	NREL (5/00)	ENTECH ⁴²
Modules					
Si	20.3 ± 0.8	1875 (ap)	80	Sandia (4/89)	Sandia/UNSW/ENTECH (12 cells) ⁴³
Low-AOD spectrum					
GaInP/GaInAs/Ge (2-terminal)	40.7 ± 2.4 [¶]	0.267 (da)	240	NREL (9/06)	Spectrolab, lattice-mismatched ⁴⁴
GaInP/GaAs/GaInAs	40.1 ± 2.4	0.0976 (da)	143	NREL (4/08)	NREL, inverted monolithic
Si	27.6 ± 1.0 [¶]	1.00 (da)	92	FhG-ISE (11/04)	Amonix back-contact ⁴⁵
Notable exceptions					
GaAs/GaSb (4-terminal)	32.6 ± 1.7	0.053 (da)	100	Sandia [§] (10/89)	Boeing, mechanical stack ⁴⁶
InP/GaInAs (3-terminal)	31.8 ± 1.6	0.063 (da)	50	NREL (8/90)	NREL, monolithic ⁴⁷
GaInP/GaInAs (2-terminal)	30.2 ± 1.2	0.1330 (da)	300	NREL/FhG-ISE (6/01)	Fraunhofer, monolithic ⁴⁸
GaAs (high concentration)	26.2 ± 1.0	0.203 (da)	1000	Sandia [§] (8/88)	Varian ⁴⁹
Si (large area)	21.6 ± 0.7	20.0 (da)	11	Sandia [§] (9/90)	UNSW laser grooved ⁵⁰

*Effic., efficiency.

[†](da), designated illumination area; (ap), aperture area.

[‡]One sun corresponds to direct irradiance of 1000 W/m².

[§]Measurements corrected from originally measured values due to Sandia recalibration in January 1991.

^{||}Not measured at an external laboratory.

The fifth new result also appears in Table I where a landmark efficiency of 1.1% is reported for a large (233 cm²) organic submodule⁹ fabricated by Plextronics and measured by NREL.

The final new result is reported in Table IV and introduces the second entry into the Tables with efficiency above 40%. An efficiency of 40.1% has been measured at 143 suns concentration (more precisely, 143 kW/m² direct irradiance) for a cell fabricated by and measured at NREL with an inverted, monolithic GaInP/GaAs/GaInAs structure and a low stress metamorphic bottom junction (see reference for 33.8% cell in Table III for more details).

DISCLAIMER

While the information provided in the tables is provided in good faith, the authors, editors and publishers cannot accept direct responsibility for any errors or omissions.

REFERENCES

- Green MA, Emery K, King DL, Igari S. Solar cell efficiency tables (version 15). *Progress in Photovoltaics: Research and Applications* 2000; **8**: 187–196.
- Green MA, Emery K, King DL, Igari S. Solar cell efficiency tables (version 17). *Progress in Photovoltaics: Research and Applications* 2001; **9**: 49–56.
- Green MA, Emery K, Hishikawa Y, Warta W. Solar cell efficiency tables (version 31). *Progress in Photovoltaics: Research and Applications* 2008; **16**(1): 61–67.
- Guemard CA, Myers D, Emery K. Proposed reference irradiance spectra for solar energy systems testing. *Solar Energy* 2002; **73**: 443–467.
- Bauhuis GJ, Mulder P, Schermer JJ, Haverkamp EJ, van Deelen J, Larsen PK. High efficiency thin film GaAs solar cells with improved radiation hardness. *20th European Photovoltaic Solar Energy Conference*, Barcelona, June 2005; 468–471.
- Contreras MA, Egaas B, Ramanathan K, Hiltner J, Swartzlander A, Hasoon F, Noufi R. Progress towards 20% efficiency in Cu(In,Ga)Se polycrystalline thin-film solar cell. *Progress in Photovoltaics: Research and Applications* 1999; **7**: 311–316.

7. Han L, Koide N, Fukui A, Chiba Y, Islam A, Komiya R, Fuke N, Yamanaka R. High efficient dye-sensitized solar cells and integrated modules. *Technical Digest, PVSEC-17*, Fukuoka, Japan, December 2007; 83.
8. Morooka M, Noda K. Development of dye-sensitized solar cells and next generation energy devices. *88th Spring Meeting of The Chemical Society of Japan*, Tokyo, 26 March 2008.
9. Laird D, Vaidya S, Li S, Mathai M, Woodworth B, Sheina E, Williams S, Hammond T. Advances in Plexcore™ active layer technology systems for organic photovoltaics: roof-top and accelerated lifetime analysis of high performance organic photovoltaic cells. *Proceedings of the SPIE*, 2007; 6656(12).
10. Zhao J, Wang A, Green MA, Ferrazza F. Novel 19.8% efficient “honeycomb” textured multicrystalline and 24.4% monocrystalline silicon solar cells. *Applied Physics Letters* 1998; **73**: 1991–1993.
11. Schultz O, Glunz SW, Willeke GP. Multicrystalline silicon solar cells exceeding 20% efficiency. *Progress in Photovoltaics: Research and Applications* 2004; **12**: 553–558.
12. Bergmann RB, Rinke TJ, Berge C, Schmidt J, Werner JH. Advances in monocrystalline Si thin-film solar cells by layer transfer. *Technical Digest, PVSEC-12*, Cheju Island, Korea, June 2001; 11–15.
13. Keevers MJ, Young TL, Schubert U, Green MA. 10% efficient CSG minimodules. *22nd European Photovoltaic Solar Energy Conference*, Milan, September 2007.
14. Venkatasubramanian R, O’Quinn BC, Hills JS, Sharps PR, Timmons ML, Hutchby JA, Field H, Ahrenkiel A, Keyes B. 18.2% (AM1.5) efficient GaAs solar cell on optical-grade polycrystalline Ge substrate. *Conference Record, 25th IEEE Photovoltaic Specialists Conference*, Washington, May 1997; 31–36.
15. Keavney CJ, Haven VE, Vernon SM. Emitter structures in MOCVD InP solar cells. *Conference Record, 21st IEEE Photovoltaic Specialists Conference*, Kissimmee, May 1990; 141–144.
16. Kessler J, Bodegard M, Hedstrom J, Stolt L. New world record Cu (In,Ga) Se₂ based mini-module: 16.6%. *Proceedings, 16th European Photovoltaic Solar Energy Conference*, Glasgow, 2000; 2057–2060.
17. Wu X, Keane JC, Dhere RG, DeHart C, Duda A, Gessert TA, Asher S, Levi DH, Sheldon P. 16.5%-efficient CdS/CdTe polycrystalline thin-film solar cell. *Conference Proceedings, 17th European Photovoltaic Solar Energy Conference*, Munich, 22–26 October 2001; 995–1000.
18. Meier J, Sitznagel J, Kroll U, Bucher C, Fay S, Moriarty T, Shah A. Potential of amorphous and microcrystalline silicon solar cells. *Thin Solid Films* 2004; **451–452**: 518–524.
19. Yamamoto K, Toshiomi M, Suzuki T, Tawada Y, Okamoto T, Nakajima A. Thin film poly-Si solar cell on glass substrate fabricated at low temperature. *MRS Spring Meeting*, San Francisco, April 1998.
20. Chiba Y, Islam A, Kakutani K, Komiya R, Koide N, Han L. High efficiency dye sensitized solar cells. *Technical Digest, 15th International Photovoltaic Science and Engineering Conference*, Shanghai, October 2005; 665–666.
21. See <http://www.konarka.com>
22. Ohmori M, Takamoto T, Ikeda E, Kurita H. High efficiency InGaP/GaAs tandem solar cells. *Technical Digest, International PVSEC-9*, Miyasaki, Japan, November 1996; 525–528.
23. Mitchell K, Eberspacher C, Ermer J, Pier D. Single and tandem junction CuInSe₂ cell and module technology. *Conference Record, 20th IEEE Photovoltaic Specialists Conference*, Las Vegas, September 1988; 1384–1389.
24. Yoshimi M, Sasaki T, Sawada T, Suezaki T, Meguro T, Matsuda T, Santo K, Wadano K, Ichikawa M, Nakajima A, Yamamoto K. High efficiency thin film silicon hybrid solar cell module on Im²-class large area substrate. *Conference Record, 3rd World Conference on Photovoltaic Energy Conversion*, Osaka, May 2003; 1566–1569.
25. Zhao J, Wang A, Yun F, Zhang G, Roche DM, Wenham SR, Green MA. 20,000 PERL silicon cells for the “1996 World Solar Challenge” solar car race. *Progress in Photovoltaics* 1997; **5**: 269–276.
26. Rose D, Koehler O, Kaminar N, Mulligan B, King D. Mass Production of PV modules with 18% total-area efficiency and high energy delivery per peak watt. *IEEE 4th World Conference on Photovoltaic Energy Conversion*, Waikoloa, HI, 7–12 May 2006; 2018–2023.
27. King DL, Schubert WK, Hund TD. World’s first 15% efficiency multicrystalline silicon modules. *Conference Record, 1st World Conference on Photovoltaic Energy Conversion*, Hawaii, December 1994; 1660–1662.
28. Basore PA. Pilot production of thin-film crystalline silicon on glass modules. *Conference Record, 29th IEEE Photovoltaic Specialists Conference*, New Orleans, May 2002; 49–52.
29. Tanaka Y, Akema N, Morishita T, Okumura D, Kushiya K. Improvement of V_{oc} upward of 600mV/cell with CIGS-based absorber prepared by selenization/sulfurization. *Conference Proceedings, 17th EC Photovoltaic Solar Energy Conference*, Munich, October 2001; 989–994.
30. Cunningham D, Davies K, Grammond L, Mopas E, O’Connor N, Rubcich M, Sadeghi M, Skinner D, Trumbly T. Large area Apollo™ module performance and reliability. *Conference Record, 28th IEEE Photovoltaic Specialists Conference*, Alaska, September 2000; 13–18.
31. Yang J, Banerjee A, Glatfelter T, Hoffman K, Xu X, Guha S. Progress in triple-junction amorphous silicon-based alloy solar cells and modules using hydrogen

- dilution. *Conference Record, 1st World Conference on Photovoltaic Energy Conversion*, Hawaii, December 1994; 380–385.
32. Zhao J, Wang A, Green MA. 24.5% efficiency silicon PERT cells on MCZ substrates and 24.7% efficiency PERL cells on FZ substrates. *Progress in Photovoltaics* 1999; **7**: 471–474.
 33. McIntosh K, Cudzonovic M, Smith D, Mulligan W, Swanson R. The choice of silicon wafer for the production of rear-contact solar cells. *Conference Record, 3rd World Conference on Photovoltaic Energy Conversion*, Osaka, May 2003; 971–974.
 34. Maruyama E, Terakawa A, Taguchi M, Yoshimine Y, Ide D, Baba T, Shima M, Sakata H, Tanaka M. Sanyo's challenges to the development of high-efficiency HIT solar cells and the expansion of HIT business. *4th World Conference on Photovoltaic Energy Conversion (WCEP-4)*, Hawaii, May 2006.
 35. McCann M, Raabe B, Jooss W, Kopecek R, Fath P. 18.1% efficiency for a large area, multi-crystalline silicon solar cell. *4th World Conference on Photovoltaic Energy Conversion (WCEP-4)*, Hawaii, May 2006.
 36. Geisz J, Kurtz S, Wanlass MW, Ward JS, Duda A, Friedman DJ, Olson JM, McMahan WE, Moriarty TE, Kiehl JT. High-efficiency GaInP/GaAs/InGaAs triple-junction solar cells grown inverted with a metamorphic bottom junction. *Applied Physics Letters* 2007; **91**: 023502.
 37. Contreras MA, Ramanathan K, AbuShama J, Hasoon F, Young D, Egass B, Noufi R. Diode characteristics in state-of-the-art ZnO/CdS/CuIn_(1-x)Ga_xSe₂ solar cells. *Progress in Photovoltaics* 2005; **13**: 209–216.
 38. Yang J, Banerjee A, Sugiyama S, Guha S. Recent progress in amorphous silicon alloy leading to 13% stable cell efficiency. *Conference Record, 26th IEEE Photovoltaic Specialists Conference*, Anaheim, September/October 1997; 563–568.
 39. Han L, Fukui A, Fuke N, Koide N, Yamanaka R. High efficiency of dye sensitized solar cell and module. *4th World Conference on Photovoltaic Energy Conversion (WCEP-4)*, Hawaii, May 2006.
 40. Kaminar NR, Liu DD, MacMillan HF, Partain LD, Ladle Ristow M, Virshup GF, Gee JM. Concentrator efficiencies of 29.2% for a GaAs cell and 24.8% for a mounted cell-lens assembly. *20th IEEE Photovoltaic Specialists Conference*, Las Vegas, September 1988; 766–768.
 41. Slade A, Garboushian V. 500x silicon concentrator cells and 20% modules for mass production. *22nd European Photovoltaic Solar Energy Conference*, Milan, 3–7 September 2007.
 42. O'Neil MJ, McDaniel AJ. Outdoor measurement of 28% efficiency for a mini-concentrator module. *Proceedings, National Center for Photovoltaics Program Review Meeting*, Denver, 16–19 April 2000.
 43. Chiang CJ, Richards EH. A 20% efficient photovoltaic concentrator module. *Conference Record, 21st IEEE Photovoltaic Specialists Conference*, Kissimmee, May 1990; 861–863.
 44. King RR, Law DC, Edmondson KM, Fetzer CM, Kinsey GS, Yoon H, Sherif RA, Karam NH. 40% efficient metamorphic GaInP/GaInAs/Ge multijunction solar cells. *Applied Physics Letters* 2007; **90**: 183516.
 45. Slade A, Garboushian V. 27.6% efficient silicon concentrator cell for mass production. *Technical Digest, 15th International Photovoltaic Science and Engineering Conference*, Shanghai, October 2005; 701.
 46. Fraas LM, Avery JE, Sundaram VS, Kinh VT, Davenport TM, Yerkes JW, Gee JM, Emery KA. Over 35% efficient GaAs/GaSb stacked concentrator cell assemblies for terrestrial applications. *Conference Record, 21st IEEE Photovoltaic Specialists Conference*, Kissimmee, May 1990; 190–195.
 47. Wanlass MW, Coutts TJ, Ward JS, Emery KA, Gessert TA, Osterwald CR. Advanced high-efficiency concentrator tandem solar cells. *Conference Record, 21st IEEE Photovoltaic Specialists Conference*, Kissimmee, May 1990; 38–45.
 48. Bett AW, Baur C, Beckert R, Diimroth F, Letay G, Hein M, Muesel M, van Riesen S, Schubert U, Siefert G, Sulima OV, Tibbits TND. Development of high-efficiency mechanically stacked GaInP/GaInAs-GaSb triple-junction concentrator solar cells. *Conference Record, 17th European Solar Energy Conference*, Munich, October 2001; 84–87.
 49. MacMillan HF, Hamaker HC, Kaminar NR, Kuryla MS, Ladle Ristow M, Liu DD, Virshup GF. 28% efficient GaAs solar cells. *20th IEEE Photovoltaic Specialists Conference*, Las Vegas, September 1988; 462–468.
 50. Zhang F, Wenham SR, Green MA. Large area, concentrator buried contact solar cells. *IEEE Transactions on Electron Devices* 1995; **42**: 144–149.